

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

Applicants : Kiyoshi AIDA et al.

Group Art Unit: Not Yet Assigned

Appl. No. : 10/565,785

(U.S. National Stage of PCT/JP2004/011352)

I.A. Filed : August 6, 2004

Examiner: Not Yet Assigned

: DUCT WALL STRUCTURE

INFORMATION DISCLOSURE STATEMENT

Commissioner for Patents
U.S. Patent and Trademark Office
Customer Service Window, Mail Stop AMENDMENT
Randolph Building
401 Dulany Street
Alexandria, VA 22314

Sir:

In accordance with the duty of disclosure under 37 C.F.R. § 1.56 and §§1.97-1.98, Applicants hereby bring the following information to the attention of the Examiner in charge of the above-identified application, which includes information cited and discussed in the specification, the International Search Report, and the International Preliminary Examination Report issued in connection with International Patent Application No. PCT/JP2004/011352, of which the present application is the U.S. National Stage Application. Copies of the International Search Report and the International Preliminary Examination Report were enclosed with the papers when entering the U.S. National Stage on January 25, 2006. The Examiner is invited to review these materials to inspect the relevance indicated during international examination with respect to the

documents cited therein. The following is a list of the documents cited in the above-noted documents:

Japanese Laid-open Patent Publication No. SHO 51-143915, together with an English language abstract of the same. Applicants note that this document is cited on page 5 of the specification of the present application;

Japanese Laid-open Patent Publication No. HEI 11-351488, together with an English language abstract of the same. Applicants note that this document is cited on page 5 of the specification of the present application;

Japanese Laid-open Patent Publication No. SHO 52-92501, together with a partial English language translation of the same. Applicants note that this document is cited on page 5 of the specification of the present application;

Japanese Laid-open Patent Publication No. HEI 9-279717, together with an English language abstract of the same. Applicants note that this document is cited on page 5 of the specification of the present application;

Japanese Laid-open Patent Publication No. 2000-27333, together with an English language abstract of the same. Applicants note that this document is cited on page 5 of the specification of the present application;

Japanese Laid-open Patent Publication No. 2002-206211, together with an English language abstract of the same;

Japanese Laid-open Patent Publication No. HEI 10-121599, together with an English language abstract of the same;

Japanese Laid-open Patent Publication No. HEI 10-205680, together with an English language abstract of the same;

P29103.A01.Doc

Japanese Laid-open Patent Publication No. HEI 6-10646, together with an English language abstract of the same;

Japanese Laid-open Patent Publication No. HEI 1-94136, together with an English language abstract of the same.

Applicants respectfully request that the Examiner consider the above material and cite the same. Copies of the above-noted foreign documents are attached hereto and all of the above-noted documents are listed on the attached PTO-1449 Form. The Examiner is requested to initial the appropriate spaces on the attached Form and to return a copy of the completed Form to Applicants with the next official communication in the present application.

Applicants note that an Office Action on the merits has not issued in the present application, and thus no fee is believed necessary to ensure consideration of the submitted material.

Should the Examiner have any questions, the Examiner is invited to contact the undersigned at the below-listed telephone number.

Respectfully Submitted, Kiyoshi AIDA et al.

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April 18, 2006 GREENBLUM & BERNSTEIN, P.L.C. 1950 Roland Clarke Place Reston, VA 20191 (703) 716-1191 FORM PTO-1449

Department of Commerce Patent and Trademark Office

Atty. Docke P29103 Application No. 10/565,785

INFORMATION DISCLOSURE STATEMENT BY APPLICANT (Use several sheets if necessary) Applicant Kiyoshi AIDA et al.

Filing Date January 25, 2006 Group Unknown

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	1 English language Abstract of JP 51-1439							3915.								
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	3 English language Abstract of JP 52-9250							2501.								
	4 English language Abstract of JP 9-279717								of JP 9-279	717.		_				
	5 English language Abstract of JP 2000-273									-27333.						
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*EXAMINER: Initial if citation considered, whether or not citation is in conformance with MPEP 609; draw line through citation if not in conformance and not considered. Include copy of this form with next communication to applicant.